

Engineered for your process - manage multiple chambers with one heater! Building off of the popular SHC product line, the Nexus incorporates the same safe indirect heating technology to heat multiple process loops. Using a single heat source, the Nexus improves chamber-temperature matching performance for advanced processing requirements.


## FEATURES

## Reduced complexity

One set of controls for up to four process chambers.
Small space requirements.

## Designed for performance

Allows for precise and stable temperature control for multiple chambers.
Low watt density design for lower surface temperatures.

## Engineered for Safety

Heats chemicals and flammable solvents through indirect contact.
Patented purged housing for leak detection.

## Advanced Cleanliness

O-ring free and crevice free design eliminates source for contamination.
All PFA wetted surfaces for acids and solvents.

## APPLICATIONS

- Semiconductor wafer cleaning


## Nexus Multi-Loop Chemical/Solvent Heater

## SPECIFICATIONS

| Wattages | 500 kW to 1400 kW |
| :---: | :---: |
| Voltages | 120 volts to 480 volts, single phase |
| Pressure Range | Up to 275 kPa ( 40 PSI ) |
| Fluid Connections | Inlets: |
|  | Low Flow: $6.3 \mathrm{~mm}\left(1 / 4^{\prime \prime}\right)$ SP300 Nippon Pillar |
|  | High Flow: $6.3 \mathrm{~mm}\left(1 / 4^{\prime \prime}\right)$ SMC Hyperflare |
|  | Outlets: |
|  | Low Flow: $3.1 \mathrm{~mm}\left(1 / \mathrm{s}^{\prime \prime}\right)$ SP300 Nippon Pillar |
|  | High Flow: 3.1mm (1/8") SMC Hyperflare |
| Safety Features | RTD core sensors |
|  | Bi-mettalic over-temp sensor |



MODEL NUMBER BREAKDOWN

| NEX | 4L | 1.4 | 6 | 1 | R | Q | H | 1 | R |
| :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: |
| Nexus Series | \# flow paths \& flow types | Wattage | Voltage | Phase | Inlet Connection | Outlet Connection | Sensor Type | TCO Rating | Element Type |
| NEX = Multi-Loop Series | 1L = 1 path low flow | . $25=250$ | 1-208 | 1 = single phase | Q $=3.1 \mathrm{~mm}$ Super 300 Pillar | Q $=3.1 \mathrm{~mm}$ Super 300 Pillar | H = RTD 100 | 1 $=90 \mathrm{C}$ | $\mathrm{R}=$ Resistive |
|  | $1 \mathrm{H}=1$ path high flow | . $4=400$ | $2=240$ |  | $\mathrm{R}=6.3 \mathrm{~mm}$ Super 300 Pillar | $\mathrm{R}=6.3 \mathrm{~mm}$ Super 300 Pillar |  |  | $\mathrm{P}=$ PTC |
|  | $2 \mathrm{~L}=2$ path low flow | . $5=500$ | $3=380$ |  | $4=6.3 \mathrm{~mm}$ SMC Hyperflare | $4=6.3 \mathrm{~mm}$ SMC Hyperflare |  |  |  |
|  | $2 \mathrm{H}=2$ path high flow | . $75=750$ | $4=400$ |  | $8=3.1 \mathrm{~mm}$ SMC Hyperflare | $8=3.1 \mathrm{~mm}$ SMC Hyperflare |  |  |  |
|  | 3L = 3 path low flow | . $8=800$ | $5=415$ |  |  |  |  |  |  |
|  | $3 \mathrm{H}=3$ path high flow | . $875=875$ | $6=480$ |  |  |  |  |  |  |
|  | $4 \mathrm{~L}=4$ path low flow | $1=1000$ | $7=440$ |  |  |  |  |  |  |
|  | $4 \mathrm{H}=4$ path high flow | $1.2=1200$ | $8=575$ |  |  |  |  |  |  |
|  |  | $1.25=1250$ | $9=220$ |  |  |  |  |  |  |
|  |  | $1.4=1400$ | $10=200$ |  |  |  |  |  |  |
|  |  | $1.6=1600$ | $12=120$ |  |  |  |  |  |  |
|  |  | $2=2000$ | $14=600$ |  |  |  |  |  |  |
|  |  |  | $15=230$ |  |  |  |  |  |  |
|  |  |  | $16=450$ |  |  |  |  |  |  |

